US PATENT PRACTICE

25 & 26 June 2015, Conf. No H6-3015



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For Promotional Opportunities email:

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25 June 2015

Dates

Start: 09.30 - Finish: 17.00 26 June 2015

Start: 09.00 - Finish: 17.00

Registration & Coffee 25 June 2015

Venue and Accommodation

The Rembrandt Hotel, 11 Thurloe Place,

London SW7 2RS

www.sarova.com/rembrandt

CONFERENCE FEES:

All fees include course documentation, mid-session refreshments and lunch.

Please tick your choice:

No accommodation:

£1,100* + VAT Accommodation NOT included

With hotel accommodation:

- £1,250.41* + VAT includes bed & breakfast for ONE night (June 25) at The Rembrandt Hotel
- £1.400.82* + VAT includes bed & breakfast for TWO nights (June 25 & 26) at The Rembrandt

Please book all accommodation, including extra nights, through Management Forum

The fee will be reduced by £150 if you book before 25 May 2015

[Discount only applicable to the full delegate rate]

Conference No. H6-3015

For Cancellation Policy and T&Cs see website

NB: Cancellations must be received in writing by registrations@management-forum.co.uk

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2-day intensive, interactive seminar

US PATENT PRACTICE



WHAT EUROPEAN PATENT ATTORNEYS **NEED TO KNOW**

11 CPD HOURS

Topics covered at this seminar:

- **US Patent Law Update**
- Claim Interpretation
- Subject Matter Eligibility
- Sufficiency of Disclosure
- Novelty, Nonobyjousness, Utility
- Inventorship
- **Double Patenting**
- Inequitable Conduct and the Duty of Candor
- Procedural aspects of US Patent Prosecution
- Interferences and Derivation Proceedings
- Post-grant Review under the AIA
- Reexamination and Supplemental Examination
- Reissues
- Direct and Indirect Infringement
- **Patent Litigation**

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COURSE LEADERS:

James V. Suggs and Nicole E. Reifman McDonnell Boehnen Hulbert & Berghoff LLP, Chicago

Register online at www.management-forum.co.uk or by phone on +44 (0)1483 730071, fax 730008



25 & 26 June 2015 The Rembrandt Hotel, London



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INTRODUCTION

US and European patent practice differs in many essential ways. The comprehensive programme of this course, with practical examples, will highlight and explain these differences from the US point of view, giving delegates a better understanding of the US system, and enabling them to work more effectively with their US counterparts.

This interactive seminar will explain:

- The latest changes in statutory law
- Recent Federal Circuit and Supreme Court jurisprudence
- Claim construction
- Successful US claim drafting
- Subject Matter Eligibility
- Sufficiency of the specification
- Nonobviousness
- Double Patenting
- Fulfilling the Duty of Candor
- Patent prosecution: Rules, Regulations and Best practices
- Interference and derivation
- Post-grant procedures
- Direct and Indirect Infringement
- Patent Litigation

And much more!

WHO SHOULD ATTEND

- Corporate Patent Counsel
- Patent Attorneys from corporate and private practice
- Intellectual Property Consultants
- · Patent Managers and Engineers
- Company Legal Advisers
- All those involved with patent protection in the United States

And anyone drafting patent applications that might serve as a priority application in the US

This course merits 11 hours CPD and may also be relevant training under the IPReg CPD self-accreditation scheme

SPEAKERS

James V. Suggs is a partner in the Chicago intellectual property law firm of MBHB, LLP, where he practices patent law. He prepares and prosecutes patent applications, prepares opinions of counsel, performs patent due diligence studies and provides patent counselling in a variety of technologies, including pharmaceutical, chemical, materials science, integrated optics, and related technologies. His litigation experience includes federal district court and appellate practice as well as advocacy in forums such as the International Trade Commission, and spans a diverse range of technologies.

Nicole E. Reifman is a partner in the Chicago intellectual property law firm of MBHB, LLP, and has diverse experience in obtaining, evaluating, and enforcing intellectual property. Ms. Reifman has experience in all phases of patent preparation and prosecution and concentrates in representing clients in the mechanical and electrical arts. She also has experience in all phases of patent litigation. Ms. Reifman also provides counselling regarding the procurement, enforcement, and licensing of intellectual property rights, including trademark and copyright issues.

Reserve your place at the course by registering online now at www.management-forum.co.uk or by fax +44 (0)1483 730008

Any questions? e-mail josephine.leak@management-forum.co.uk

ATTENDANCE LIMITED – EARLY REGISTRATION RECOMMENDED

This limitation, a unique feature of all **MANAGEMENT FORUM** seminars, will give participants the opportunity for a thorough discussion of the complex issues to be covered by the programme.

A Certificate of Attendance for Professional Development will be given to each participant who completes the course

Programme

- Providing the latest state of US Patent Law, including the latest legislative changes under the America Invents Act, recent and pending US Supreme and other Court decisions of importance, and current happenings in the USPTO
- Giving specification and claim drafting tips to give your applications a solid footing for US prosecution and enforcement.
- Claim Construction
- 35 U.S.C. § 112 Specification, Enablement, Written Description, Claims
- ▶ 35 U.S.C. § 101 Patentable Subject Matter
- ▶ 35 U.S.C. § 101 Utility
- 35 U.S.C. § 102 Novelty
 - All elements rule
 - Analysis of pre-AIA 35 U.S.C. § 102(a)-(g)
 - Analysis of post-AIA 35 § 102 comparison and contrast with pre-AIA law
 - · How the USPTO is adapting to change to 'first-to-file' system

35 U.S.C. § 103 - Non-obviousness

- The factual inquiries of Graham v. John Deere
- The Supreme Court's latest guidance KSR v. Teleflex
- · Responding to obviousness rejections in the USPTO
- Common ownership, joint development and obviousness
- Obviousness under the AIA how changes in the definition of prior art affect obviousness determinations

Patent Prosecution

- Provisional applications
- Continuation and Continuation-in-Part applications
- Restriction Practice and Divisional applications
- Patent term and Patent term adjustment
- Accelerated and Prioritised Examination
- · Patent Prosecution Highway

Obviousness-Type Double Patenting

► The Duty of Candor

- Avoiding inequitable conduct
- · Time and manner of citing prior art
- Disclosure of related prosecution

Inventorship

Interference and Derivation Proceedings

- Interferences pre-AIA applications
- · Conception and reduction to practice
- Derivation proceedings in post-AIA applications, as compared to interferences
- Best practices in documenting conception, diligence and reduction to practice

Post Issue Practice

- Post-grant review under the AIA
- Re-examination procedure and strategy
- Supplemental examination
- Re-issue
- Certificates of Correction

35 U.S.C. § 271 - Infringement

- Markman proceedings in the courts
- Literal Infringement
- Doctrine of Equivalents analysis
- Indirect Infringement liability for infringement by others
- Joint infringement method claims with a third-party performing a "step"
- Infringement by importation into the US 35 U.S.C. § 271(g)
- Willful infringement
- Notice of Infringement preparation, and response: Declaratory Judgments
- Certificates of Correction

► Patent Litigation and the Liberal Scope of Discovery

- Remedies to the Victor Belong the Spoils
 - Damages: How determined, how to factor into your claim drafting
 - Injunctions